

### 993SM - Laboratory of Computational Physics Unit XI - II part December 6, 2024

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Università degli Studi di Trieste – Dipartimento di Fisica Sede di Miramare (Strada Costiera 11, Trieste) e-mail: <u>peressi@units.it</u> tel.: +39 040 2240242 Modelling other random processes

Fractals & Diffusion Limited Aggregates
Percolation

# **Diffusion Limited Aggregation**

Several examples of formation of natural patterns showing common features:



#### **Electrodeposition**:

cluster grown from a copper sulfate solution in an electrodeposition cell



#### Dielectric breakdown:

High voltage dielectric breakdown within a block of plexiglas

These common features that can be captured by very simple models:

# **Diffusion Limited Aggregation**

- simple model of FRACTALS GROWTH, initially proposed for irreversible colloidal aggregation, although it was quickly realized that the model is very widely applicable.
- by T.A. Witten and L.M. Sander, Phys. Rev. Lett. 47, 1400 (1981)



REAL IMAGE (Atomic Field Microscopy) of a gold colloid of about 15 nm over a gel substrate

SIMULATION

# **DLA: algorithm** \* Start with an immobile seed on

the plane

\*A walker is then launched from a random position far away and is allowed to diffuse

\* If it touches the seed, it is immobilized instantly and becomes part of the aggregate

\*We then launch similar walkers one-by-one and each of them stops upon hitting the cluster

\* After launching a few hundred particles, a cluster with intricate branch structures results



# DLA: algorithm - details

- We launch walkers from a "launching circle" which inscribes the cluster
- They are discarded if they wander too far and go beyond a "killing circle"
- The diffusion is simulated by successive displacements in independent random directions
- At every step, the walker which would aggregate is checked to detect any overlapping with the particles on the cluster

### **DLA: results**



# DLA: interesting quantities

- in a "normal" 2D object:  $N \propto r^2$
- FRACTAL DIMENSION: the number of particles N with respect to the maximum distance r of a particle of the cluster from its center of mass is  $N\propto r^{D_f}$ , with

 $1 < D_f < 2$ 



# DLA: algorithm - details II

- the simplest DLA models: diffusion on a lattice. On a square lattice, 4 adjacent sites are available for the diffusing particle to stick
- modification: the particle will stick with certain probability (the "sticking coefficient")
   to simulate somehow the surface tension
- another modification: with a sort of Brownian diffusion in the continuum

### **DLA: results**

 $1 < D_f = 1.6 < 2$ 

Sticking Coefficient  $\xi = 1$ .



### **DLA:** results

Sticking Coefficient  $\xi = 0.5$ 



## Models of surface growth



see e.g. Barabasi & Stanley, Fractal concepts in surface growth, Cambridge University Press

# Models of surface growth

#### The Eden model - algorithm:

- (a) choose randomly a lattice site and occupy it. The *nearest neighbor sites* of the occupied site (i.e. 4 sites in case of a square lattice) are the *perimetral sites*.
- (b) choose randomly a *perimetral site* and occupy it. When occupied, it is no longer a *perimetral site*: update the list of *perimetral sites* with the new ones. Repeat from (1).

#### **Interesting quantities:**

Average height: 
$$\bar{h} = \frac{1}{N_s} \sum_{i=1}^{N_s} h_i$$

Roughness:

$$w^2 = \frac{1}{N_s} \sum_{i=1}^{N_s} (h_i - \bar{h})^2,$$

### Modelling other random processes

- Fractals & Diffusion Limited Aggregates
- Percolation
- Monte Carlo approach for classical fluids

## Percolation

geometric connectivity in a stochastic system; modeling threshold and transition phenomena



existence of a critical occupation fraction  $P_c$  above which spanning clusters occur (in nature: mixtures of conducting/insulating spheres...; resistor networks..) 15

## Percolation

- metal/insulator threshold behavior in resistor networks (discrete percolation) and in alloys (continuous percolation)

Other examples:

- fluid adsorption in a porous medium
- spreading of a disease in a population
- spreading of a forest fire...
- liquid/glass transition...



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By Rudolf A. Römer

## Percolation

Definitions:

p: occupation probability of each identity (site, bond)

Cluster: group of identities (sites, bonds,...) connected by nearest neighboring bonds

Percolating clusters: connecting two boundaries

### which is the critical percolation threshold $p_c$ ?

Example of site percolation on a lattice:







## Percolation threshold

### **p**<sub>c</sub> depends on the criteria (different possibilities):

Connection along one fixed direction



Connection along one (any, horizontal or vertical) direction



Connection in all directions



## Percolation threshold

**p**<sub>c</sub> depends on the criteria (different possible):



 $P_C(1) \equiv P_C(2) \quad \text{for} \quad L \to \infty$ 

## Monte Carlo approach



## Results

#### for different percolation criteria and different size

Connection along one fixed direction



Connection along one (any, horizontal or vertical) direction



Connection in all directions



0.70



## Results

for different percolation criteria and different size



## Results

for different percolation criteria and different size



#### extrapolate the behavior for

 $L \to \infty$  $1/L \to 0$ 



 $P_C^{\infty}(1) = P_C^{\infty}(2) = 0.59 \pm 0.05$ 

### **Results** other interesting quantities



## Cluster labelling



The (non trivial) part of the model: choose a smart algorithm to identify and label the clusters made of adjacent occupied sites

## Cluster labelling









(1): span all the cells
 (here: left => right
 and bottom => up)
 and start labeling

(2): attribute the minimum cluster label to cells neighboring to different clusters

(3): refine labeling

### Hoshen- Kopelman algorithm for clusters labelling

# Example of application in solid state physics

#### **Dynamical Percolation Model of Conductance Fluctuations in Hydrogenated Amorphous Silicon**



A model of a-Si:H from https://doi.org/10.1016/j.commatsci.2018.08.027 L.M. Lust e J. Kakalios, Phys. Rev. Lett. 75, 11 (1995)

Fluttuazioni di conduttività nel silicio amorfo idrogenato (*a*-Si:H) sono simulate utilizzando un modello dinamico di diffusione di resistenze in un reticolo in condizioni di soglia di percolazione. Una frazione di siti di reticolo è designata come una trappola tale per cui quando un resistore diffonde in una di esse, rimane localizzato per un periodo finito di tempo.



Fluttuazioni di conduttività misurate sperimentalmente





Rete casuale di resistenze con P ~  $P_C$  (fisso)

Configurazione dopo un riarrangiamento casuale dei legami

### Diffusione H:

Creazione/distruzione canali di conduttività





### Percolation on different lattices





TRIANGULAR z=6	SQUARE z= 4	KAGOME' z = 4	HONEYCOMB z=3
ρ <sup>SITE</sup> ≖ 0.5000 ¢	p <sup>5ITE</sup> = 0.593 c	p <sup>SME</sup> =0.6527 c	p <sup>SITE</sup> =0.70 c